

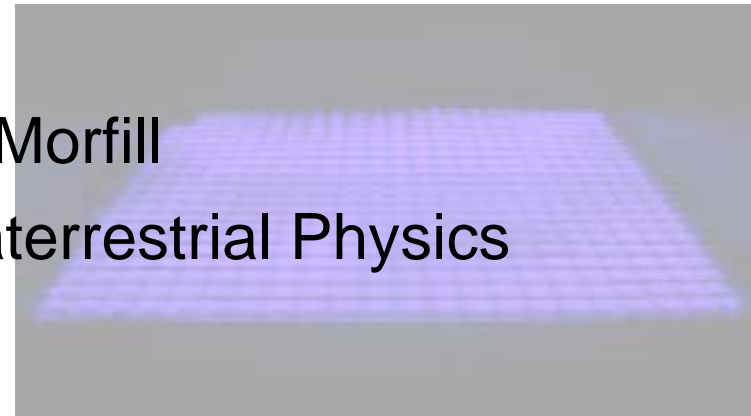
Modeling of Plasma Chemistry of Hand Plasma Sterilization Device

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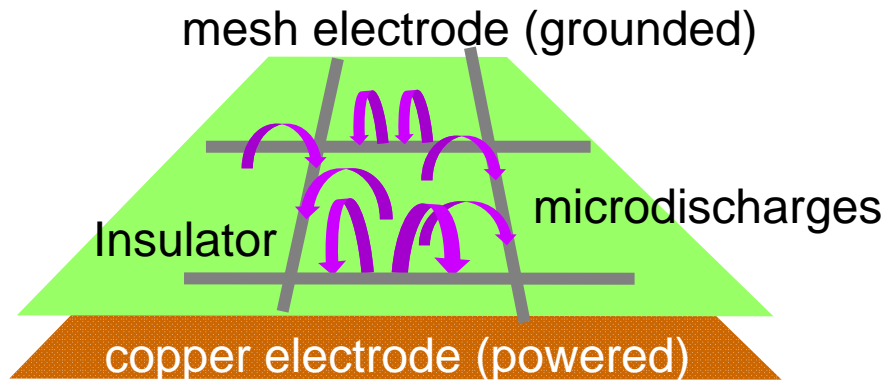
Tetsuji Shimizu and Gregor E. Morfill

Max Planck Institute for Extraterrestrial Physics



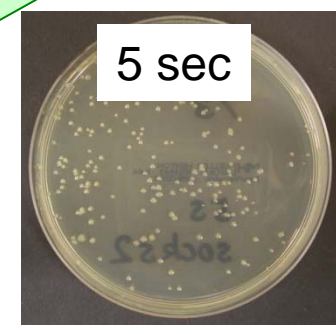
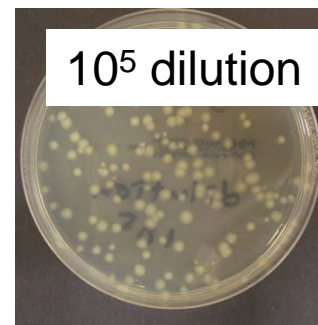
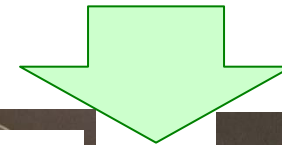
Motivation: hand sterilization dispenser

G. Morfill et al., New J. Phys. **11**, 115019 (2009)



- Power: 50 Watts/100 cm²
- Voltage: 5-10 kV_{pkpk}
- Frequency: 1-10 kHz

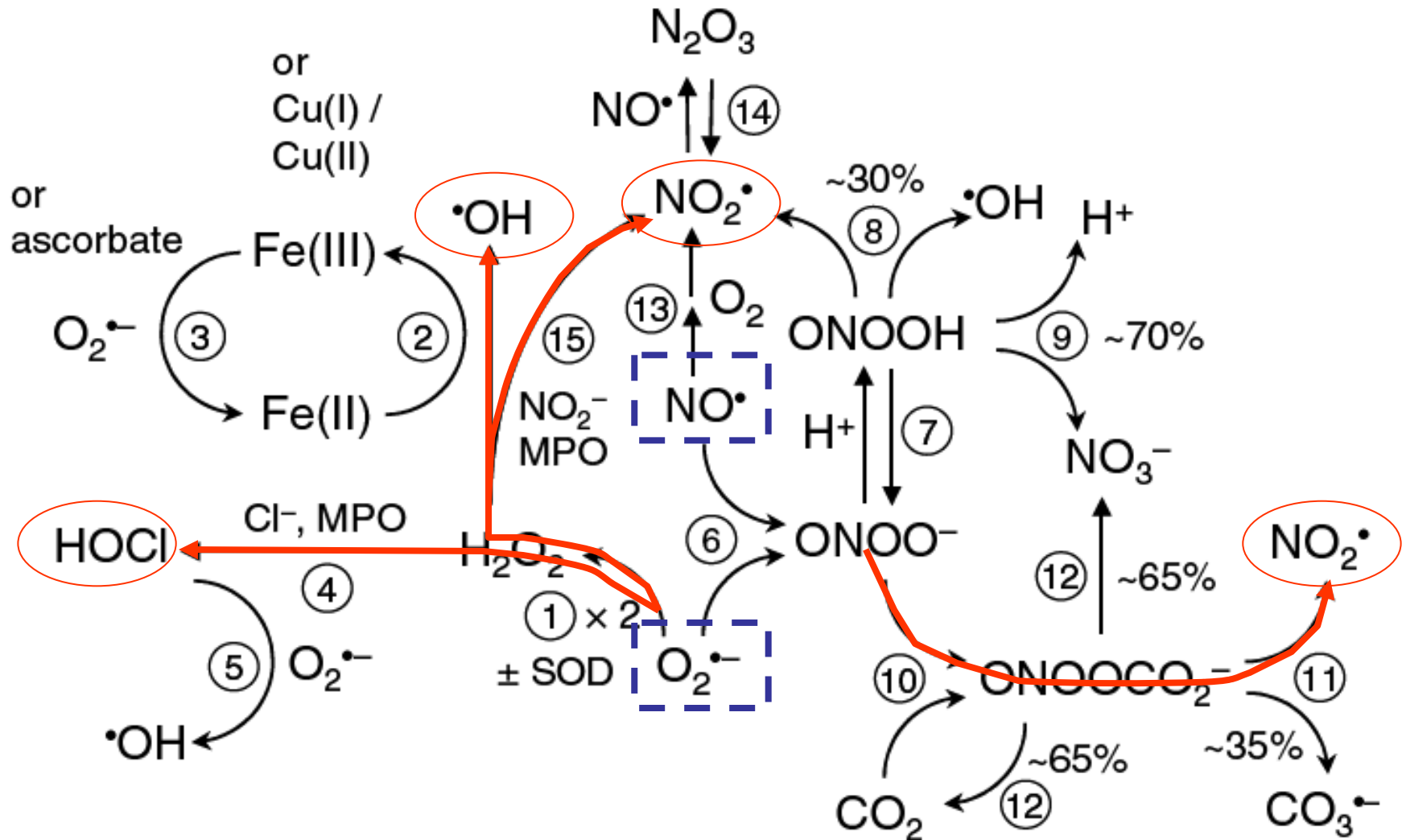
Sterilization through socks



T. Shimizu, et al. Wed 10:15am!

Motivation: importance of ROS/RNS

R. B Mikkelsen, Oncogene **22** (2003) 5734

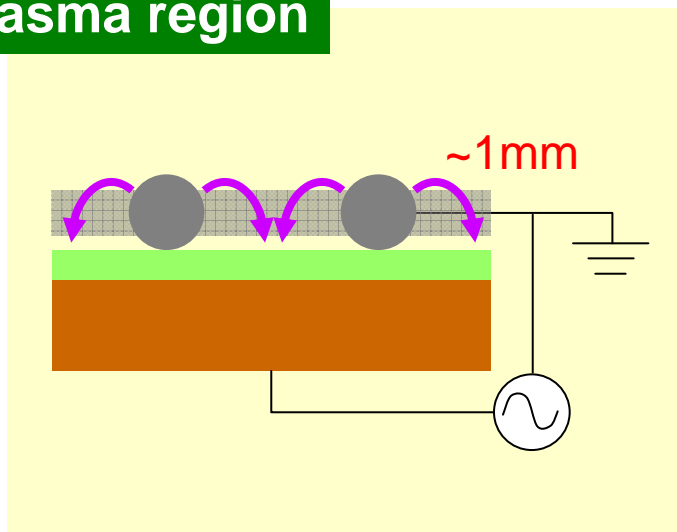


Model: strategy

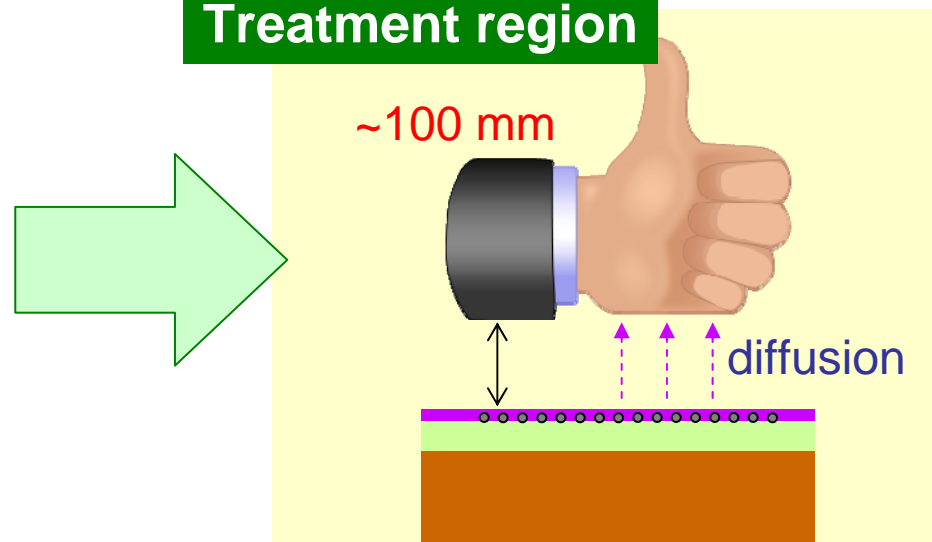
The goal of the project

- Developing numerical models to predict the device performance
- Controlling ROS/RNS to optimize the therapeutic effects

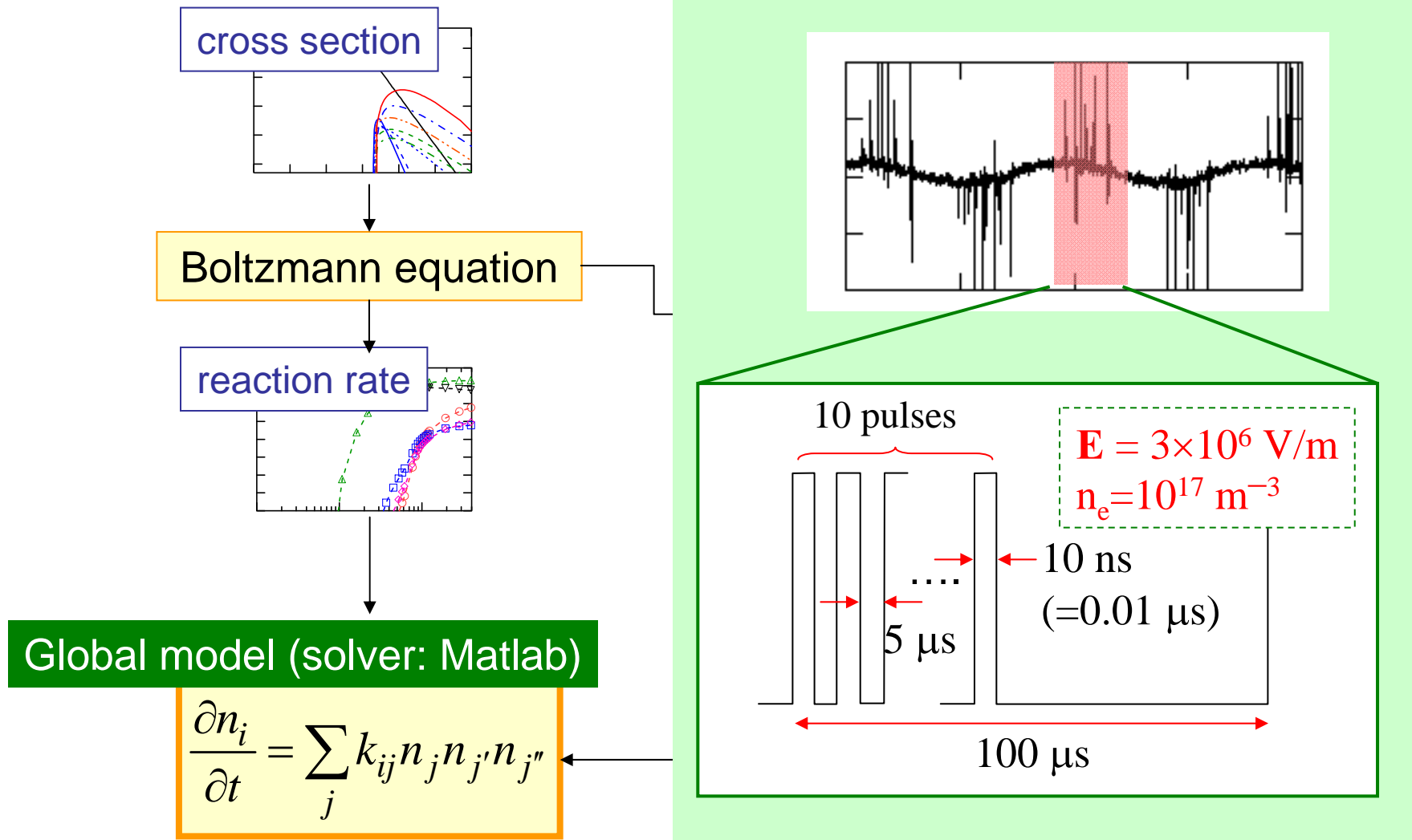
Plasma region



Treatment region



Model: governing equation



Model: plasma chemistry

48
species

11 negative particles: e , O^- , O_2^- , O_3^- , O_4^- , H^- , OH^- , NO^- ,
 N_2O^- , NO_2^- , NO_3^-

16 positive particles: N^+ , N_2^+ , N_3^+ , N_4^+ , O^+ , O_2^+ , O_4^+ , NO^+ , N_2O^+ ,
 NO_2^+ , H^+ , H_2^+ , H_3^+ , OH^+ , H_2O^+ , H_3O^+

21 neutrals:
 N , N^* , N_2 , N_2^* , N_2^{**} , O , O^* , O_2 , O_2^* , O_3 ,
 NO , N_2O , NO_2 , NO_3 , N_2O_5 , H , H_2 , OH ,
 H_2O , HO_2 , H_2O_2

630
reactions

21 electron impact excitation/ionization/dissociation

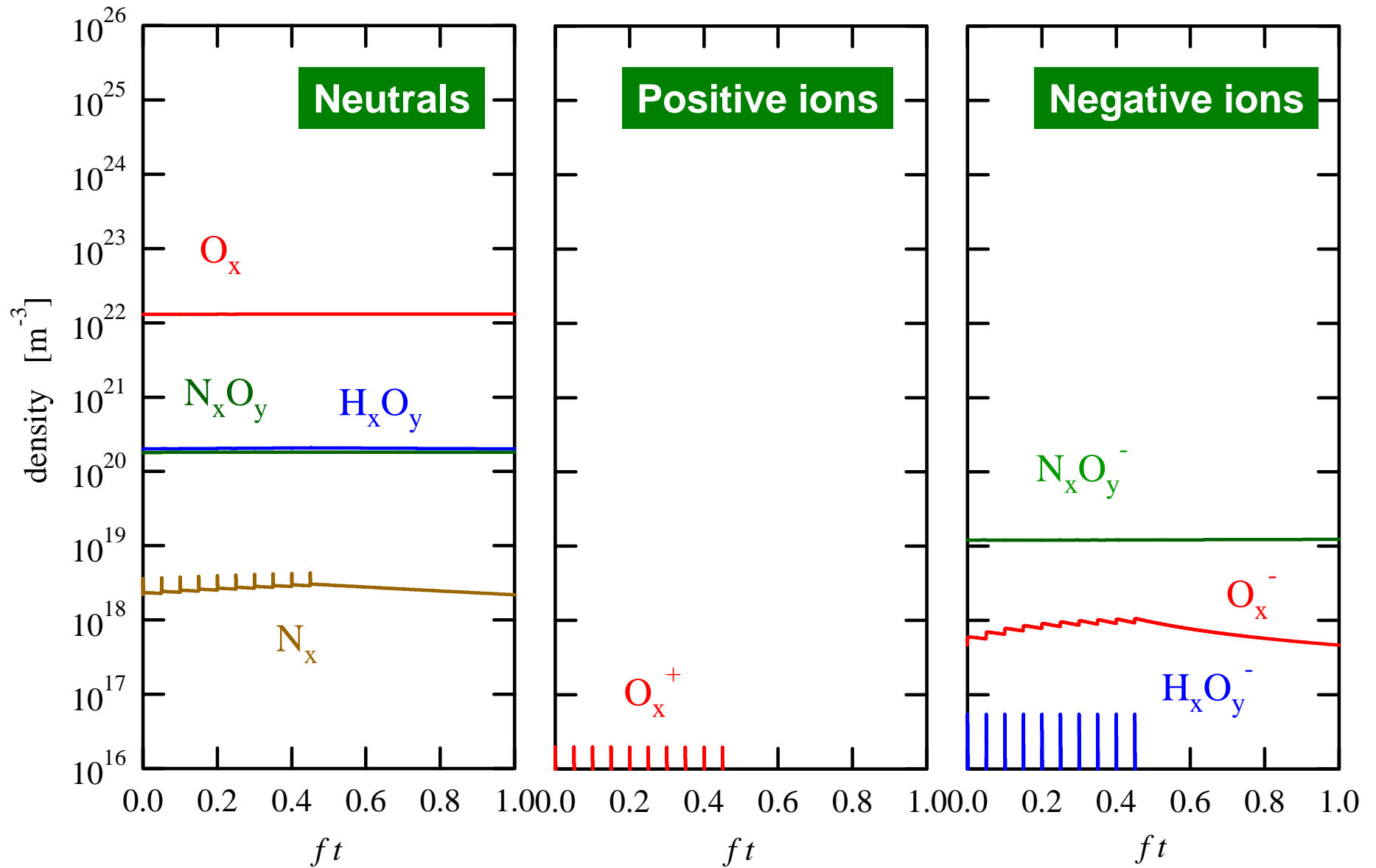
76 electron recombination/attachment

159 charge transfer

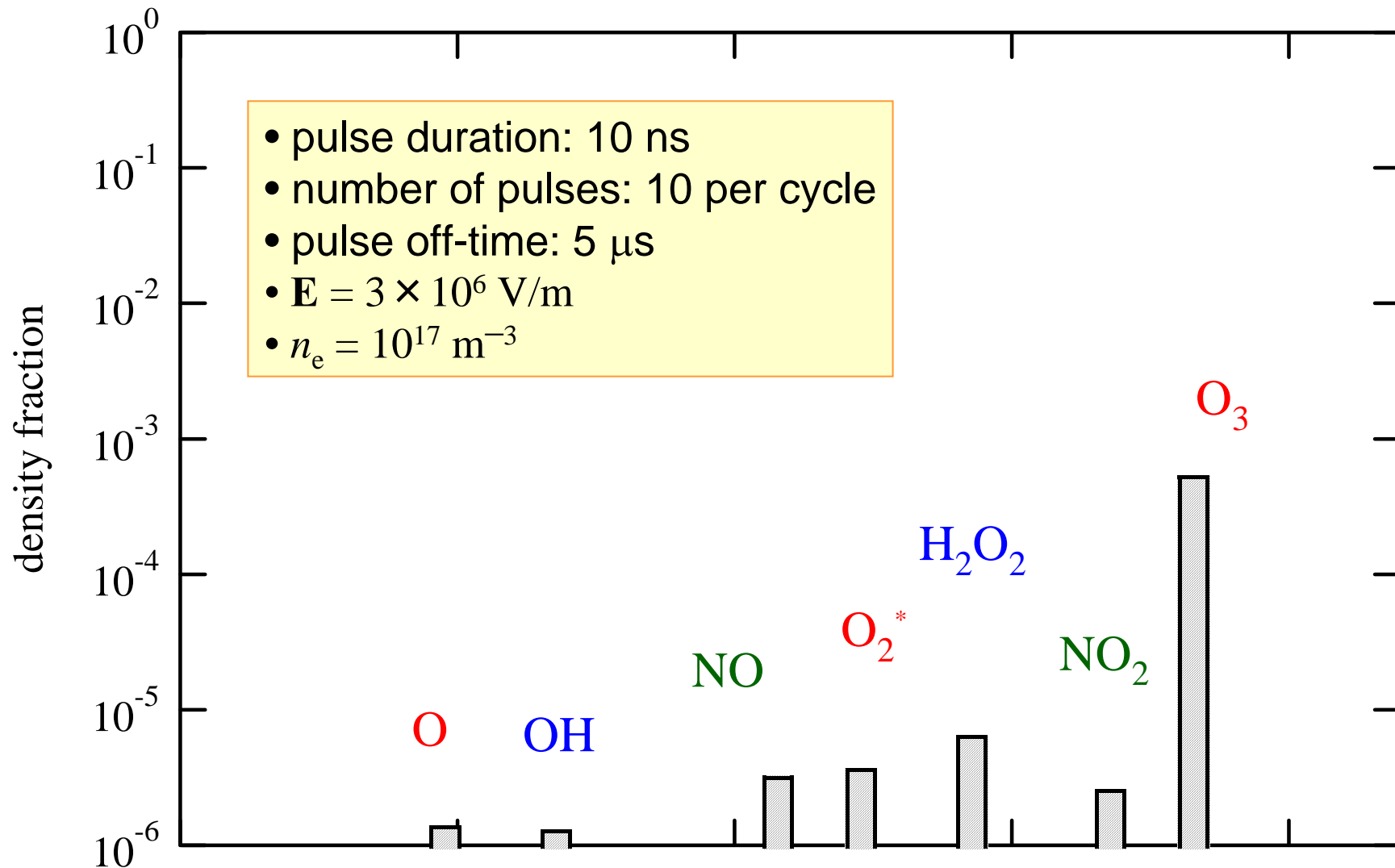
245 ion recombination

129 neutral-neutral reactions

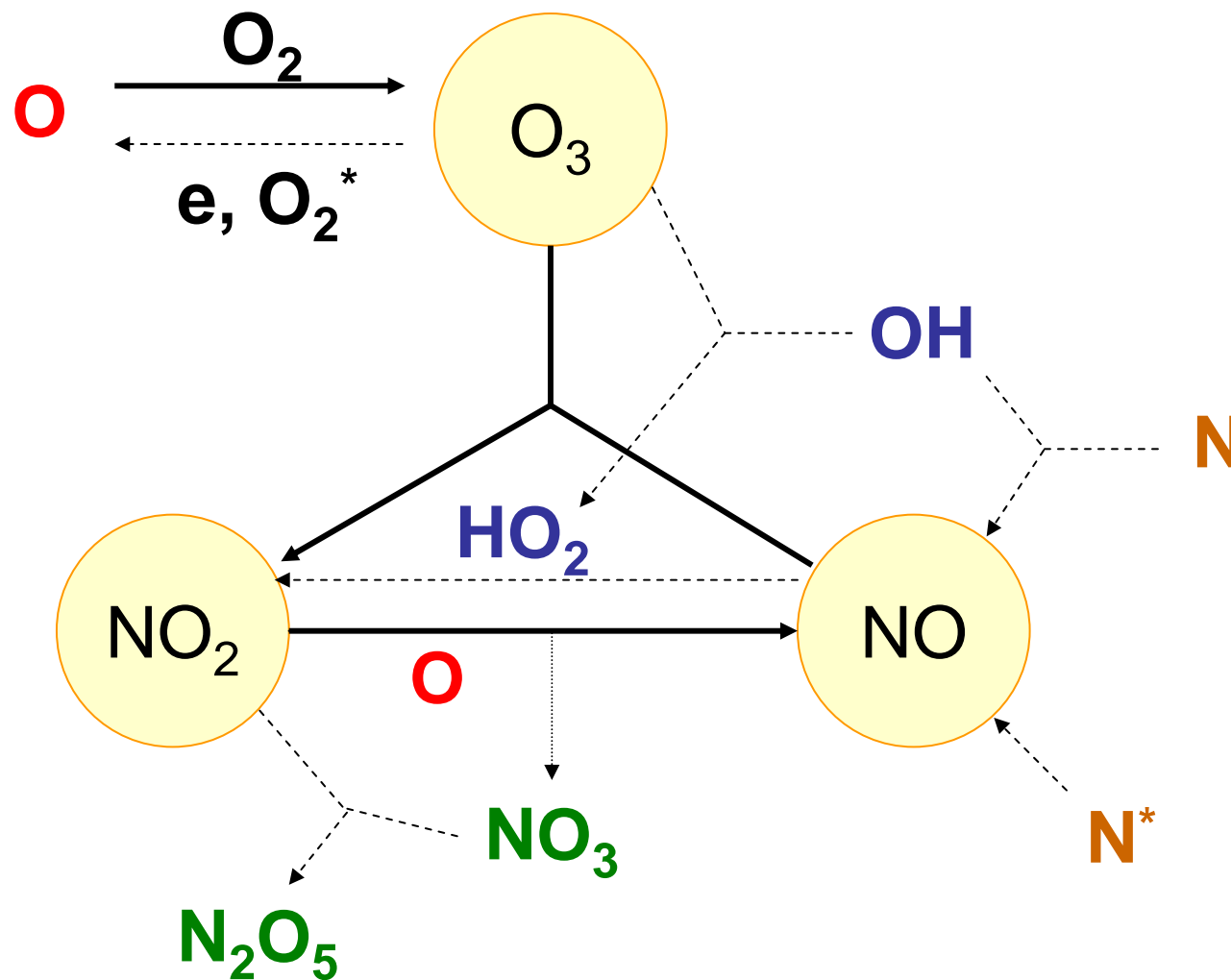
Dynamics of reactive species



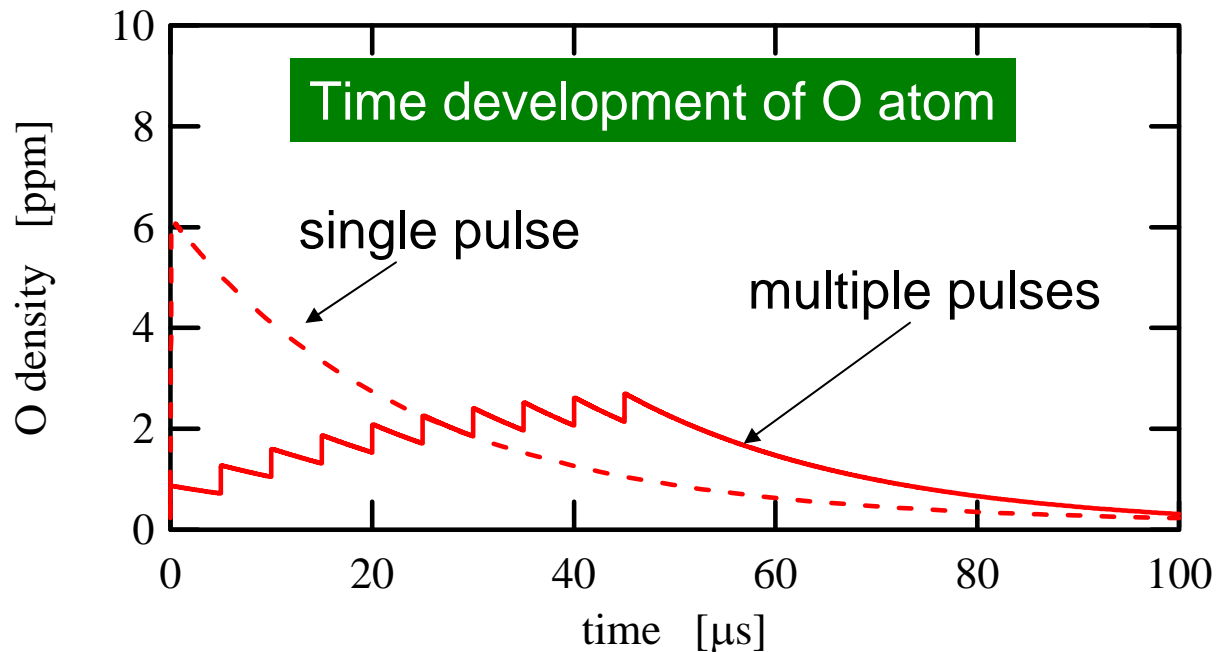
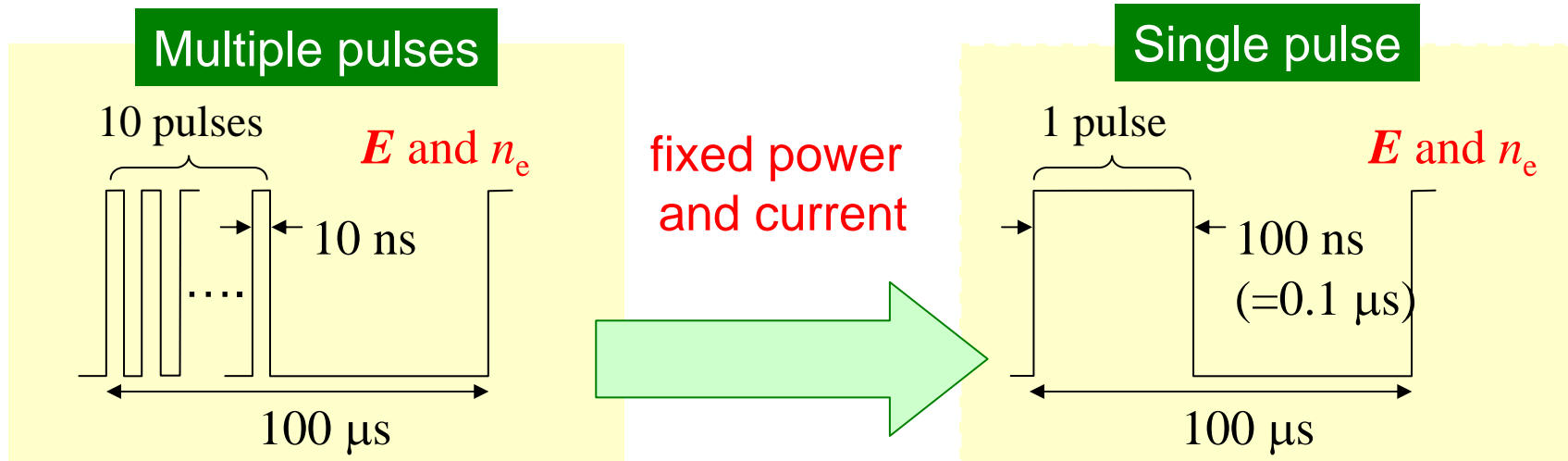
Phase-averaged density



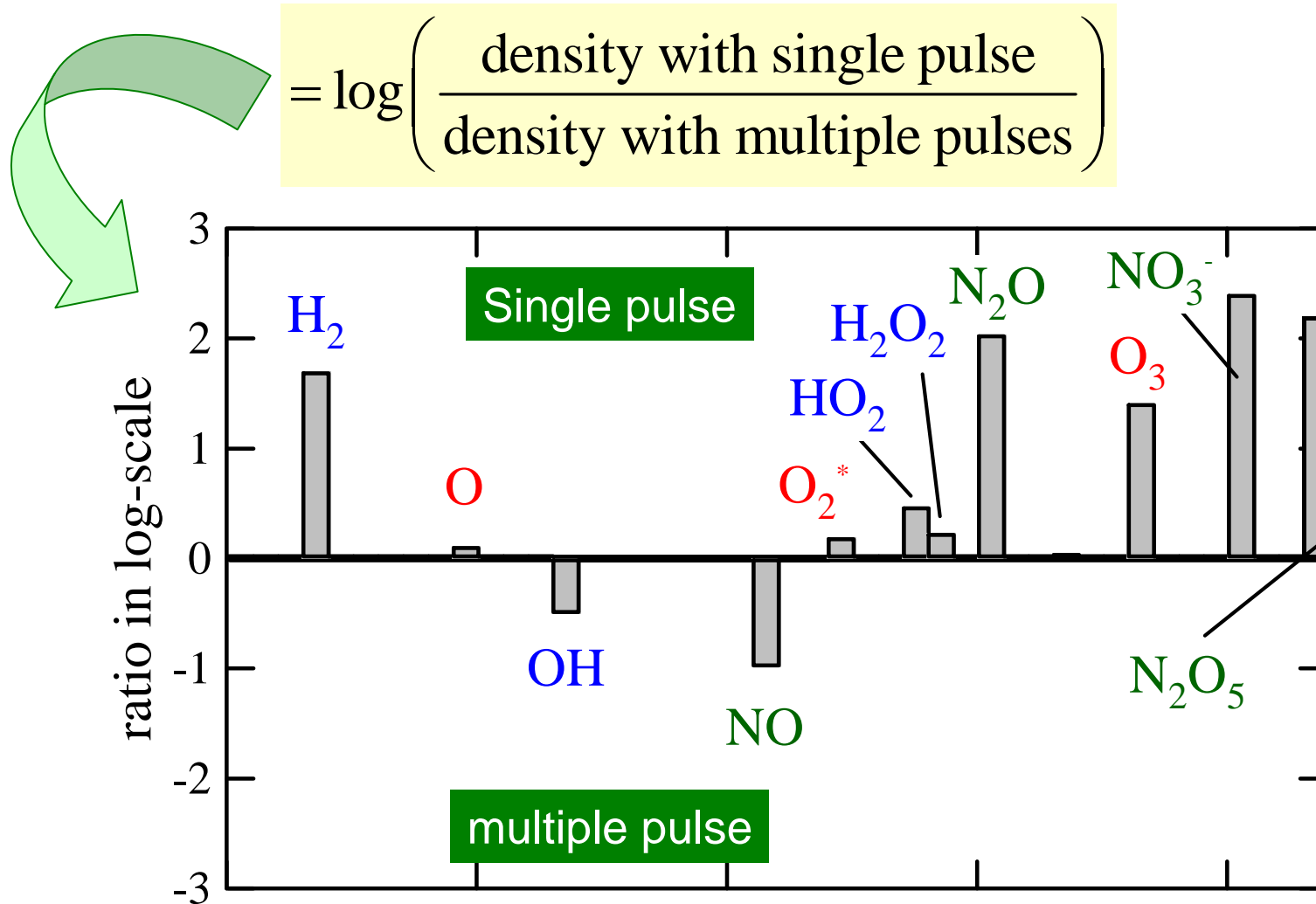
Reaction networks between O_3 , NO, and NO_2



Control of plasma chemistry (1)



Control of plasma chemistry (2)



Concluding Remarks

1. We have developed a global model of air barrier corona discharge.
2. A global model for air BCD suggests the most abundant species is O_3 , followed by H_2O_2 , O_2^* , NO , NO_2 , O , and OH .
3. Concentration of ROS/RNS can be controlled by modifying the discharge current waveform.